## ABSTRACT

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structure and a fabrication method metallurgical connections between solder bumps and contact 5 pads positioned on integrated circuits (IC) having copper interconnecting metallization protected by an overcoat. The structure comprises а portion of the metallization exposed by a window in the overcoat, where the exposed copper has a chemically and plasma cleaned 10 A copper layer is directly positioned on the surface. clean copper metallization, and patterned; the resulting metal structure has an electrical (and thermal) conductivity about equal to the conductivity of pure The copper layer overlaps the perimeter of the copper. overcoat window and a copper stud is positioned on said copper layer. Finally, one of the solder bumps is bonded to the copper stud.